

Electronic Acknowledgement Receipt

EFS ID:	1312151
Application Number:	10805890
International Application Number:	
Confirmation Number:	1896
Title of Invention:	Method of plasma etching of high-K dielectric materials with high selectivity to underlying layers
First Named Inventor/Applicant Name:	Padmapani C. Nallan
Customer Number:	44182
Filer:	Keith Patrick Taboada
Filer Authorized By:	
Attorney Docket Number:	7017 C1/ETCH/METAL-NVM/JB
Receipt Date:	14-NOV-2006
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Application Type:	Utility

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Submitted with Payment	yes
Payment was successfully received in RAM	\$ 130
RAM confirmation Number	1652
Deposit Account	

File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
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1		Appm_7017C1_RFOA.pdf	337960	yes	8				
	Multipart Description/PDF files in .zip description								
	Document Description		Start	End					
	Amendment After Final		1	1					
	Claims		2	4					
	Applicant Arguments/Remarks Made in an Amendment		5	7					
	Terminal Disclaimer Filed		8	8					
Warnings:									
Information:									
2	Fee Worksheet (PTO-875)	fee-info.pdf	8200	no	2				
Warnings:									
Information:									
Total Files Size (in bytes):			346160						
<p>This Acknowledgement Receipt evidences receipt on the noted date by the USPTO of the indicated documents, characterized by the applicant, and including page counts, where applicable. It serves as evidence of receipt similar to a Post Card, as described in MPEP 503.</p> <p><u>New Applications Under 35 U.S.C. 111</u> If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.</p> <p><u>National Stage of an International Application under 35 U.S.C. 371</u> If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.</p>									